IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Tokumi KOBAYASHI

T. C. Art Unit: 2123

Appl. No.

: 10/596,088 (National Stage

of PCT/JP2004/017467)

Examiner: S. S. Rao

I. A. Filed

: November 25, 2004

Confirmation No · 1724

For

: CIRCUIT SUBSTRATE PRODUCTION METHOD AND SYSTEM, SUBSTRATE USED THEREIN, AND CIRCUIT SUBSTRATE USING

THE SAME

AMENDMENT UNDER 37 C.F.R. § 1.111

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Service Window, Mail Stop <u>Amendment</u>
Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

This paper is in response to the Official Action November 27, 2010, setting a three month period for response extending until March 1, 2010 (February 27, 2010 being a Saturday). If any extension of time is necessary, this is an express request for any necessary extension of time and authorization to charge any required extension of time fee, or any other fees that may be required to preserve the pendency of the present application, to Deposit Account No. 19-0089.

Applicant respectfully requests reconsideration and withdrawal of the outstanding rejection in view of the herein contained amendments and remarks.

Amendments to the Claims begins on page 2 of this response.

Remarks/Arguments begins on page 13 of this response.